This article was downloaded by:

On: 30 January 2011

Access details: Access Details: Free Access

Publisher Taylor & Francis

Informa Ltd Registered in England and Wales Registered Number: 1072954 Registered office: Mortimer House, 37-

41 Mortimer Street, London W1T 3JH, UK



Phosphorus, Sulfur, and Silicon and the Related Elements

Publication details, including instructions for authors and subscription information: http://www.informaworld.com/smpp/title~content=t713618290

PHOTOCHEMICAL C-S BOND CLEAVAGE IN METHYL ARYL SULFIDES AND SULFOXIDES. A CIDNP STUDY OF REACTIVITY ENHANCEMENT BY METHYLTHIO GROUPS.¹

Reinhard Lüdersdorf^a; Igor Khait^a; Karol A. Muszkat^a; Klaus Praefcke^b; Paul Margaretha^c ^a Department of Structural Chemistry, The Weizmann Institute of Science, Rehovot, Israel ^b Institut für Organische Chemie, C3, Technische Universität Berlin, Berlin, Germany ^c Institut für Organische Chemie und Biochemie, Universität Hamburg, Hamburg, Germany

To cite this Article Lüdersdorf, Reinhard , Khait, Igor , Muszkat, Karol A. , Praefcke, Klaus and Margaretha, Paul(1981) PHOTOCHEMICAL C-S BOND CLEAVAGE IN METHYL ARYL SULFIDES AND SULFOXIDES. A CIDNP STUDY OF REACTIVITY ENHANCEMENT BY METHYLTHIO GROUPS. Phosphorus, Sulfur, and Silicon and the Related Elements, 12: 1, 37 -54

To link to this Article: DOI: 10.1080/03086648108078288 URL: http://dx.doi.org/10.1080/03086648108078288

PLEASE SCROLL DOWN FOR ARTICLE

Full terms and conditions of use: http://www.informaworld.com/terms-and-conditions-of-access.pdf

This article may be used for research, teaching and private study purposes. Any substantial or systematic reproduction, re-distribution, re-selling, loan or sub-licensing, systematic supply or distribution in any form to anyone is expressly forbidden.

The publisher does not give any warranty express or implied or make any representation that the contents will be complete or accurate or up to date. The accuracy of any instructions, formulae and drug doses should be independently verified with primary sources. The publisher shall not be liable for any loss, actions, claims, proceedings, demand or costs or damages whatsoever or howsoever caused arising directly or indirectly in connection with or arising out of the use of this material.

PHOTOCHEMICAL C—S BOND CLEAVAGE IN METHYL ARYL SULFIDES AND SULFOXIDES. A CIDNP STUDY OF REACTIVITY ENHANCEMENT BY METHYLTHIO GROUPS.¹

REINHARD LÜDERSDORF, IGOR KHAIT and KAROL A. MUSZKAT

Department of Structural Chemistry, The Weizmann Institute of Science, Rehovot, Israel

and

KLAUS PRAEFCKE

Institut für Organische Chemie, C3, Technische Universität Berlin, Strasse des 17. Juni 135, D-1000 Berlin, Germany

and

PAUL MARGARETHA

Institut für Organische Chemie und Biochemie, Universität Hamburg, D-2000 Hamburg, Germany

(Received April 9, 1981; in final form July 21, 1981)

Proton photo CIDNP studies indicate that ring substitution of the methylthio group in methyl phenyl sulfoxide or in methyl phenyl sulfide results in a strong enhancement of the methyl-S bond cleavage reactivity. In sulfoxides bond cleavage originates from the triplet state born radical pair ³RP1 (³ArSO + CH₃) formed by direct excitation or by ketone triplet sensitization. Strong emission is observed in the methyl protons of the escape products of ³RP1, CH₄, C₂H₆ and ArSCH₃. The polarization in the sulfide product establishes that photodeoxygenation of sulfoxides takes place in the arylsulfinyl radical following the C—S photocleavage step. The collapse path of ³RP1 (giving back the parent molecule) is readily recognized, giving rise to enhanced absorption in the methyl protons of the methylsulfinyl group and emission in the ring protons ortho to that group. In the di(methylthio) benzenes C—S bond photocleavage has now been clearly established giving rise to polarized ethane and methane by the escape path.

INTRODUCTION

As shown earlier, ^{2-4b} free radical paths in sulfur photochemistry⁵ are directly amenable to investigation by the CIDNP⁶ method which is product specific and usually can provide significant mechanistic information. In addition, CIDNP studies are also of direct relevance to the characterization of the complementary concerted electrocyclic counterparts of free radical paths. Thus far, among the free radical paths of photoreactions of organo-sulfur compounds we have investigated the photodecarboxylation of arylthioacetic acids² and the carbon-sulfur photocleavage process. ^{3,4b} Concerning this last process we have recently observed large variations in the C—S bond photocleavage reactivity in sulfoxides. ^{3,4b} In the common case, as in methylphenylsulfoxide and in its 4-substituted derivatives ArSOCH₃, the C—S bond photocleavage is a very inefficient process which can be detected by ¹H NMR through the formation of trace amounts of polarized methane (CH⁴₄). This product

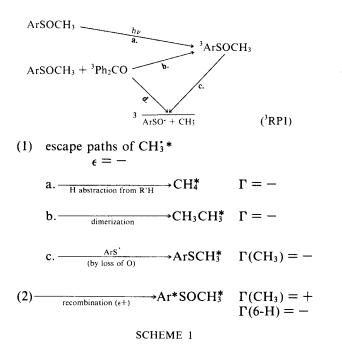
is obtained from the escape path of the triplet state born (and electron spin correlated) radical pair ${}^3ArSO^2 + CH_3^2({}^3RP1)$. The free radical photochemical paths of the photoreactive sulfoxides (see below) are summarized in Scheme 1. Step (1) of Scheme 1 takes place on triplet sensitization while direct excitation (whenever effective) leads to photocleavage from both triplet- or singlet-state born radical pairs, through the escape paths of 3RP1 or 1RP1 .

We have observed a considerable enhancement of the triplet state C—S bond photocleavage reactivity in the following special classes of sulfoxides:

A. Ortho-substituted methyl-phenyl sulfoxides, $2-X-C_6H_4SOCH_3$, e.g., X = -COOR, -CONHR, $-CONR_1R_2$, -NHCOR, -CHO, and $-C_6H_5$. In these compounds escape path (1a) leads to the formation of methane in considerable yields and with a large nuclear polarization. Proton polarized ethane is also formed by escape path (1b) as are the corresponding methyl-polarized methylsulfides $2-X-C_6H_4SCH_3^*$, obtained by scavenging of CH_3^* by thiyl radicals $2-X-C_6H_5S^*$ (path 1c) formed in the deoxygenation process of the arylsulfinyl radicals.

However, in addition to the escape paths (1a-1c) these molecules show also evidence for a significant extent of recombination in ³RP1, leading to methyl- and ring-polarized ArSOCH₃ (path 2). The whole degenerate photochemical cycle described in Scheme 1, e.g. formation of ³RP1 (by steps **a.** and **c.**, or **b.** and **c.**, or by step **d.**), followed by (2), provides a 'no-reaction' dissipation path for electronic excitation energy as well as one possible mechanism for photoracemization of sulfoxides (cf. Ref. 5b), the exact weight and scope of which remain yet to be fully evaluated.

Other ortho substituents (X=Cl, Br, I, CH₃, COOH, NH₂, CH₂OH) do not exert any significant effects on the reactivity pattern described above for 4-X-C₆H₄SOCH₃(X=H, CH₃, Br). 3,4b



B. Methyl-Vinyl Sulfoxides. 4b Closely related to the reactive sulfoxides of group A are the methyl cyclopentenyl sulfoxide 1, and its cyclohexenyl homolog. Thus 1

gives rise to polarized methane, ethane and methyl sulfide RaSCH3 by the escape path, and to polarized 1 through recombination. 4b

$$\begin{array}{c}
O \\
\parallel \\
C - S - \\
S - CH_3
\end{array}$$
O

1

C. Benzyl, Allyl, and Pentadienyl Sulfoxides. 4b Strong C—S bond photocleavage reactivity has also been observed in sulfoxides with especially weak bonds such as cinnamyl-fluorenyl sulfoxide 2 and the phenyl-pentadienyl sulfoxide 3. The CIDNP experiments indicate that the fluorenyl-sulfinyl and cinnamyl-sulfinyl bonds of 2 and the pentadienyl-sulfinyl bond of 3 undergo photocleavage which in this group is largely reversible (see Scheme 1).4b

H
S-CH₂-CH=CH-C₆H₅

$$C_6H_5$$
 C_6H_5 -S-CH₂-CH=CH-C=CH₂
 CH_3
 CH_3

Methyl aryl sulfides corresponding to the sulfoxides discussed in A and B show usually little own free radical photochemical reactivity. Thus the ortho type facilitating effect acting on sulfoxides is not sufficient to promote significant bond cleavage reactivity in the corresponding methyl aryl sulfides. However, methyl aryl sulfides undergo readily a reversible H atom photoabstraction by triplet benzophenone (cf. Scheme 3 and also Refs. 2 and 10). In the present paper we wish to describe an additional type of structural element which strongly enhances C—S bond photocleavage reactivity in both sulfoxides and sulfides. Substitution of the methylthio group (CH₃S) at the benzene ring of methylphenyl sulfoxide (4) as in compounds 5, 6 and 7 results in significant photocleavage reactivity and surprisingly enough the same group shows also a strong facilitating effect on the parallel photoprocess of methylphenyl sulfide (8) which is otherwise almost completely inert to C—S cleavage by either direct excitation or triplet benzophenone sensitization.

RESULTS AND DISCUSSION

(Methylthio) Methylsulfinyl Benzenes. Methylthio-group substitution at the three ring positions leads to significant methyl-sulfinyl bond cleavage reactivity for both direct excitation (Figures 1, 3 and 5) as well as for triplet benzophenone (BP) sensitization (Figures 2, 4 and 6). The free radical photochemical processes involved

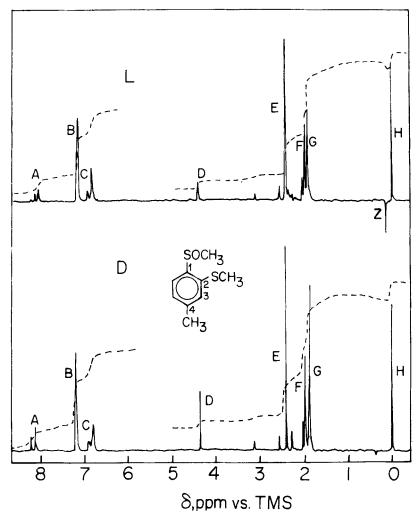


FIGURE 1 90 Mhz ¹H photoCIDNP in 4-methyl-1-methylsulfinyl-2-methylthiobenzene (5, 0.2M) benzene-d₆ solution, direct excitation. **D**, dark spectrum; **L**, light spectrum (see Experimental). Assignment: A, 6-H; B, solvent; C, 3-H and 5-H; D, impurity; E, SOCH₃; F, SCH₃; G, ArCH₃; H, TMS; Z, CH₄.

are summarized in Scheme 1. Polarized methane (signal Z in Figures 1-6, δ 0.18 in C_6D_6) is observable in emission, in every case. Polarized ethane (signal Y, δ 0.68, E effect) is observable, both on triplet benzophenone sensitization (Figures 2 and 6) and on direct excitation (Figures 3 and 5). Signals X (Figures 2, 4-6) are the negatively polarized methyl protons of the sulfide product (e.g. 9, 10, 11) formed by the deoxygenation process (cf. Ref. 51) of the corresponding sulfoxide (5, 6, and 7) according to the general path of deoxygenation, (1a) followed by (3) and (1c) (cf. Scheme 1),

$$ArSO^{\bullet} \xrightarrow{-[O]} ArS^{\bullet}$$
 (3)

The observed negative polarization of the methyl protons of the three escape products of ³RP1 (methane, ethane and Ar'SCH₃) is in agreement with the predic-

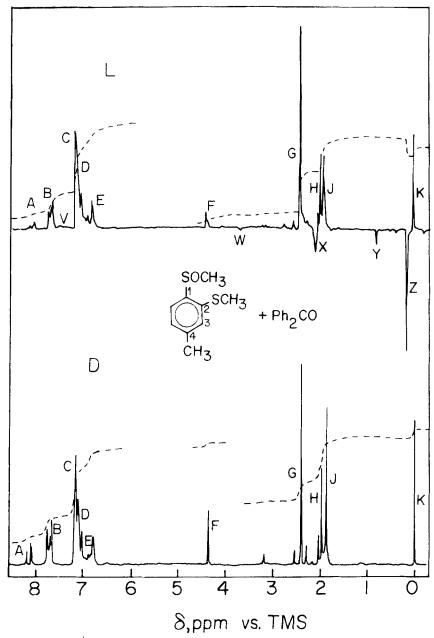


FIGURE 2 90 Mhz ¹H photoCIDNP in 5, 0.2M in benzene-d₆ in the presence of benzopnenone (BP, 0.1M) see caption to Figure 1. Assignment: 5-A, 6-H; E, 3-H and 5-H; G, SOCH₃; H, SCH₃; J, ArCH₃. BP—B, H ortho; D, other aromatic H. K, TMS; C, solvent. Products: Z, CH₄; Y, C₂H₆; X, probably Ar'SCH₃; W, methylene of Ph₂COH—CH₂SAr'; V, probably ortho H of Ph (of same); F, impurity.

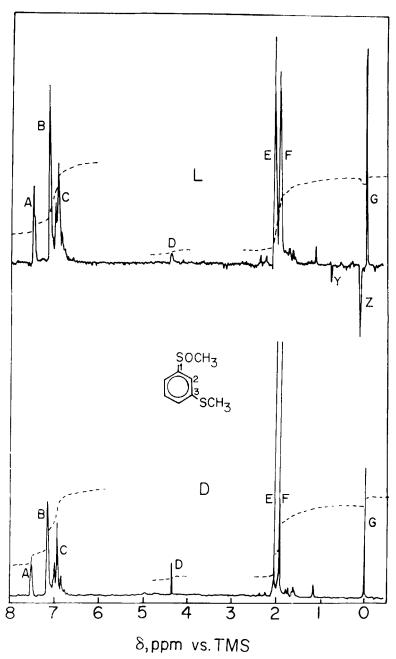


FIGURE 3 ¹H photoCIDNP in 1-methylsulfinyl-3-methylthiobenzene, 6, 0.2M in benzene-d₆, direct excitation. See caption to Figure 1. Assignment: 6-A, 2-H; C, other aromatic H; E, SOCH₃, F, SCH₃. B, solvent; D, impurity; G, TMS; Y, C_2H_6 ; Z, CH₄. Signal at δ 1.2 is due to HDO.

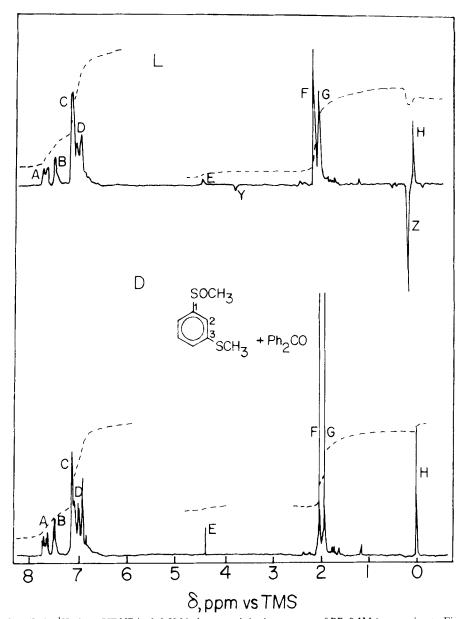


FIGURE 4 ¹H photoCIDNP in 6, 0.2M in benzene-d₆ in the presence of BP, 0.1M (see caption to Fig. 1) 6: B, 2-H; D, Ar-H; F, SOCH₃; G, SCH₃. H, TMS; A, H ortho of BP. C, solvent; E, impurity; Y, methylene of Ph₂COH—CH₂SAr'; Z, CH₄.

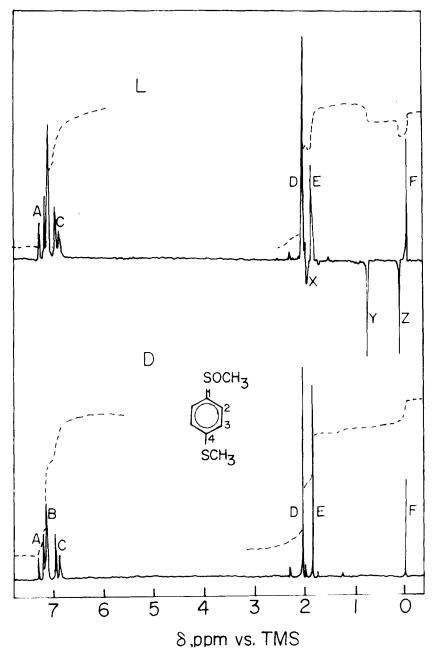


FIGURE 5 ¹H photo CIDNP in 1-methylsulfinyl-4-methylthiobenzene (7, 0.2M) in benzene-d₆ solution, direct excitation (see caption to Figure 1). 7:A, 2-H and 6-H; C, 3-H and 5-H; D, SOCH₃; E, SCH₃. B, solvent; F, TMS. Products: X, SCH₃ of 11; Y, C₂H₆; Z, CH₄.

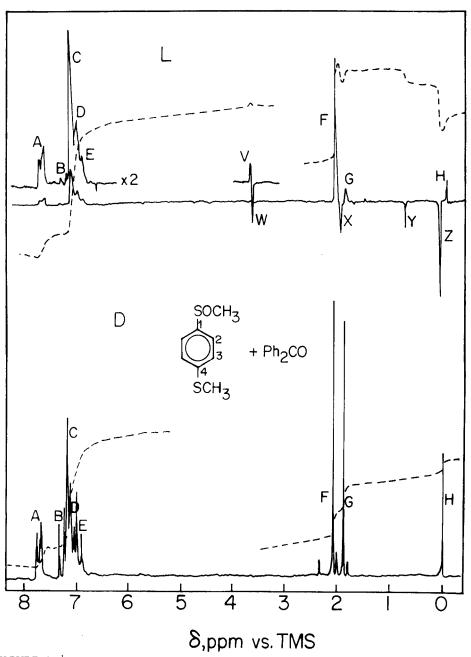


FIGURE 6 ¹H photo CIDNP in 7 (0.2M in benzene-d₆) in the presence of BP (0.1M). See caption to Figure 1. 7: B, 2-H and 6-H; E, 3-H and 5-H; F, SOCH₃; G, SCH₃. BP: A, H ortho; D, other Ar-H. C, solvent; H. TMS. Products: W, methylene of Ph₂COH—CH₂SAr'; X, SCH₃ of 11; Y, C₂H₆; Z, CH₄; V, unassigned.

tion of the Radical Pair model⁷ [μ +, ϵ -, $A(CH_3^*)$ - and Δg -, as $g(CH_3^*)$ < $g(ArSO^*)$, cf. Ref. 2-4b, 8, 12 so that Γ , according to $\Gamma = \mu \cdot \epsilon \cdot \Delta g \cdot A_i$ is negative]. The total electronic spin state is a triplet for all radical pairs involved as the nuclear polarization in all products formed by both direct excitation and triplet sensitization is of the same sign. The polarization of methane obtained from singlet ¹RP1 shows an opposite (positive) sign. ^{3,4b,13}

The present systems show ample evidence for the recombination path (2), Scheme 1, of the triplet born ³RP1, ³ArSO' + CH₃. Strong enhanced absorption is observed in the sulfinyl methyl protons of 5 (G in Figure 2), of 6 (F in Figure 6) and of 7 (D in Figure 5) while a negative effect is observed in the 6-H protons of 5 (A in Figure 2). The direct excitation results indicate that the 4-methylthio compound is the most reactive as far as photocleavage is concerned, and the fact that significant additional reactivity is evoked by the triplet benzophenone excitation of the 2- and 3- methylthio compounds (e.g. cf. Figure 1 with Figure 2) indicates that in both the photochemical reactivity is controlled (and limited) by the rate of intersystem crossing.

The enhanced absorption effect observed in the methyl protons of the ${}^{3}RP1$ recombination product is also well reproduced by the Radical Pair model. With the exception of $\epsilon+$ the other three parameters are as for the escape path so that Γ [Eq. (a) footnote 6] = ++-- = +. The CIDNP effects described here, especially those of Figures 2, 4, 5 and 6, leave little doubt that the C—S photocleavage taking place in these systems is at the methylsulfinyl groups

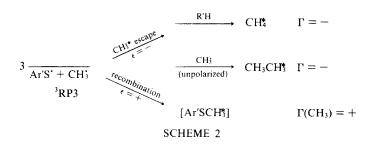
$$^{3}ArSOCH_{3} \longrightarrow ^{3}\overline{ArSO' + CH'_{3}}$$
 (1)

and not at the methylthio groups

$$^{3}\text{Ar'SCH}_{3} \longrightarrow ^{3}\overline{\text{Ar'S}} + \overline{\text{CH}}_{3}^{*}$$
 (4)

The recombination process of ³Ar'S' + CH₃ (³RP3), Scheme 2, would lead to polarization in the methyl protons of the methylthio groups which has not been observed

in these compounds. The methyl sulfinyl path seems to be preferred over the methylthio path for energetic reasons (see below). Factors of direct electronic origin also play an important role in directing the reaction to this path. Preliminary results obtained by studying low temperature effects on the absorption spectra in ethanol of 5-7 and 9-11 indicate that the first transition in both types of molecules is a necessarily locallized $n \to \pi^*$ transition involving the sulfur atom.¹⁴



In 9-11 this transition is at higher energies than in the corresponding sulfoxides, a fact which indicates that the lowest electronic transition in 5-7 is a $n-\pi^*$ transition largely locallized at the methylsulfinyl group. The results of the triplet benzophenone sensitization of the photocleavage of 5 and 6 (Figures 2 and 4) show evidence for traces of H atom abstraction by triplet benzophenone. This abstraction is probably from the methylthio group (path 5a) as in arylmethylsulfides, cf. Scheme 3,

$$Ar'SCH_3 + {}^{3}Ph_2CO \longrightarrow \overline{{}^{3}Ar'SCH_2' + Ph_2COH'}$$
 (5a)

and not from the methylsulfinyl group, path 5b,

$$ArSOCH_3 + {}^{3}Ph_2CO \longrightarrow {}^{3}ArSOCH_2 + Ph_2COH'$$
 (5b)

SCHEME 3

Signals W in Figure 2, Y in Figure 4, and W in Figure 6 are from the methylene protons of the collapse product 12* of ³RP5 (see below).

Photo CIDNP studies indicate that process (5a) is a general path of triplet quenching by arylthioacetic acids,² methylthioaromatics⁸ and higher alkyl arylsulfides.¹⁰ Thus in the present cases triplet energy transfer to the methylsulfinyl group of 5 and 6 should be considerably faster than both energy transfer to the methylthio group¹⁶ or H atom abstraction by the triplet benzophenone from that group.

Compounds 5, 6 and 7 [unlike the di(methyl thio) benzenes 9-11, see below] show only a limited extent of H atom abstraction as evidenced from emission signals W (Figure 2 and 6) and Y (Figure 4), assigned to the methylene of the recombination product Ph₂COHCH₂*SAr'(12*) of ³RP5.

The photocleavage of compound 5 shows the reactivity expected as a result of the introduction of a facilitating substituent, much in common with the effect of substitution at the 3 and 4 ring positions. However the present results do not point to a special ortho type (neighboring group) effect as in the reactive systems of group A (cf. Introduction and Ref. 3, 4b) nor do they indicate any evidence for an intramolecular oxygen transfer from the methylsulfinyl group to the methylthio group, to give 5'.

$$CH_{3}-S=O$$

$$CH_{3}-C$$

$$CH_{3}-C$$

$$CH_{3}-$$

Because of the photodealkylation, this process would result in nuclear polarization in the 3-H ring proton of 5.

DI(METHYLTHIO)BENZENES

The most reactive molecule of this series with respect to the C—S bond cleavage in the methylthio group is the ortho di(methylthio) derivative 9, which undergoes significant photocleavage on direct excitation (Figure 7) as well as on triplet benzophenone sensitization (Figure 8). In the first instance both negatively polarized methane and ethane are formed, as expected for the methyl-sulfur methylthio group cleavage (process 4). Triplet sensitization (Figure 8) leads to polarized methane and to the photo abstraction signal Y of the methylene protons in the collapse product $(C_6H_5)_2COH-CH_2^*$ SAr' (see Scheme 3). The fate of the arylthiyl radical Ar'S' is obscure.

The lack of methyl polarization in Ar'SCH₃ due to the recombination path of ³RP3 (Scheme 2) could be the result of cancellation by the opposite sign polarization from the collapse process (7) of ³RP5 in Scheme 3. This finding in 9 is in contrast with the effect observed in 5 for ³RP1 (see Figure 2). The ArSOCH₃ and Ar'SCH₃ bond dissociation energies (55 vs. 67 Kcal/mole)¹⁵ suggest that recombination in ³RP3 would be faster than in ³RP1. Lack of polarization in ³RP3 would

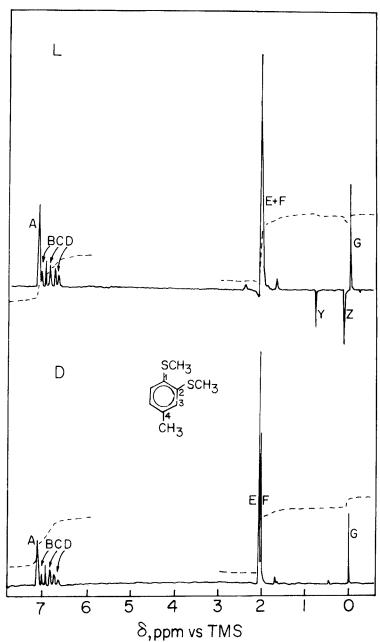


FIGURE 7 ^{-1}H photo CIDNP in 4-methyl-1,2-di(methylthio) benzene (9, 0.2M) in benzene-d₆ solution. See caption to Figure 1. 9: B, 6-H; C, 3-H; D, 5-H; E or F, SCH₃ or ArCH₃. G, TMS; Y, C₂H₆; Z, CH₄.

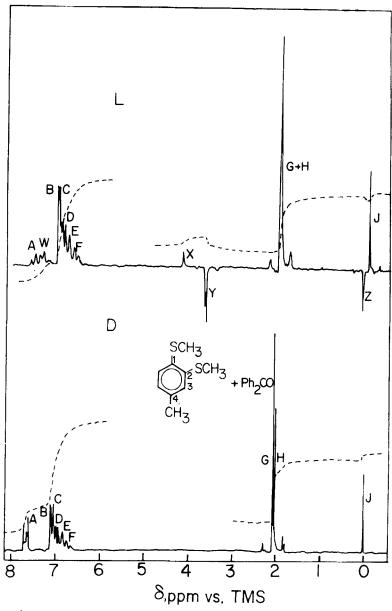


FIGURE 8 ¹H photo CIDNP in 9 (0.2M) in benzene-d₆ in the presence of BP (0.1M). See caption to Figure 1. 9: D. 6-H; E, 3-H; F, 5-H; G or H, SCH₃ or ArCH₃. BP: A, H ortho; and C, other aromatic protons. B, solvent; J, TMS. Ph₂COH—CH₂SAr': Y, methylene; W, possibly ortho phenyl protons. Z, CH₄; X, unassigned.

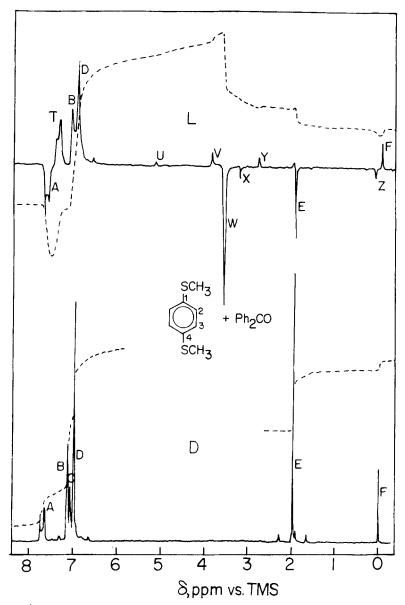


FIGURE 9 ¹H photo CIDNP in 1,4-di(methylthio)-benzene (11, 0.2M) in benzene-d₆ solution in the presence of BP (0.1M). 11: D, aromatic protons, E, SCH₃. BP: A, H ortho; C, other protons. B, solvent; F, TMS. Products: Z, CH₄: Y, methylene of Ar'SCH₂CH₂SAr'; W, methylene of Ph₂COH—CH₂SAr', T, ortho phenyl protons of same. U. V and X, unassigned.

indicate that other competing processes such as H abstraction or dimerization intervene.

In the para-di(methylthio) compound 11 no C—S photocleavage is observed on direct excitation. Benzophenone sensitization (Figure 9) leads to H atom abstraction from the methylthio group as the most prominent process which results in polarization in both collapse and escape products of ³RP5 (Scheme 3), e.g.

Ar'SCH2*CPh2*(12*) (path 6, signals W and T), Ar'SCH3* (path 7, emission, OH

Ar'SCH₂*CH₂SAr' (13* path 8, signal Y) and Ph₂*CO (path 9, signal A). Path 10, leading to the parent molecule by the escape route is observable in the presence of thiophenol. In 11 the photocleavage can be observed only as a minor path leading to polarized methane. In the meta di-(methylthio) benzene 10 no C—S photocleavage takes place, either by direct excitation or by triplet sensitization, the only photochemical process observed being the H atom photoabstraction by triplet benzophenone (Scheme 3).

The signs of the polarized protons of all the recombination and escape products of ${}^{3}\text{RP5}$ are fully accounted for by Eq. (a), ${}^{6}\Gamma = \mu \cdot \epsilon \cdot \Delta g \cdot A_i$. Here $\mu +$ and $g(\text{Ar'SCH}_{2}^{2}) > g(\text{Ph}_{2}\text{COH'})$. All polarized protons have negative hfs factors (A-). The polarization signs derived from Eq. (a) are shown in the right-hand side of Scheme 3.

THE ENERGETICS OF C-S CLEAVAGE

The photo polarization pattern in the methyl aryl sulfoxides ArSOCH₃ observed in this and in the previous work^{3,4b} is compatible only with cleavage of the methyl-sulfur bond but not with a cleavage of the aryl-sulfur bond. The same conclusion holds for the methyl-aryl sulfides.⁸ This cleavage mode is a natural outcome of the different bond strengths of the CH₃—S and of the Ar—S bonds.¹⁵ The estimates for these (in Kcal/mole) are D(CH₃—SOC₆H₅) < 55, D(CH₃SO—C₆H₅) \simeq 66; D(CH₃—SC₆H₅) = 67 and D(CH₃S—C₆H₅) = 89.¹⁵ Much the same can be said concerning the preference for C—S photocleavage in the methylsulfinyl group over the C—S photocleavage of the methylthio group in compounds 5-7, as the methylarylsulfinyl bond is weaker by some 10 Kcal/mole than the methyl-arylthio bond.

These bond dissociation energy data thus indicate that the triplet state energy of benzophenone, $E_T = 69$ Kcal/mole^{17b} is sufficient for a fast direct cleavage process in many sulfoxides, e.g. path **d** of Scheme 1

$$^{3}\text{Ph}_{2}\text{CO} + \text{ArSOCH}_{3} \longrightarrow ^{3}\overline{\text{ArSO'} + \text{CH}'_{3}} + \text{Ph}_{2}\text{CO}$$
 (d)

as $D(CH_3-SOAr) < 55$ Kcal/mole.

However it seems now that in several methylphenyl sulfoxides the E_T of benzophenone is too low to reach ³ArSOCH₃ as intermediate in the formation of ³RP1 (path b in Scheme 1, followed by c). Thus in a polar medium ³p-BrC₆H₄SOCH₃ is at 79 Kcal/mole, ¹⁸ and similar values are obtained for several other p-substituted phenyl sulfoxides. ¹³ It is at present unclear whether the same situation holds in the case of ortho substituted or methylthio-substituted methyl-phenyl sulfoxides.

For the parallel sensitized cleavage of methyl phenyl sulfide and most of its derivatives.

$$^{3}\text{Ph}_{2}\text{CO} + \text{Ar'SCH}_{3} \longrightarrow {}^{3}\overline{\text{Ar'S'} + \text{CH}_{3}} + \text{Ph}_{2}\text{CO}$$
 (e)

the triplet energy of benzophenone seems to be insufficient to guarantee a fast process (as $D(Ar'S-CH_3) = 67$ Kcal/mole) in agreement with the experimental findings for these molecules. Thus it seems certain that the methyl-S bond dissociation energies of the di(methylthio) benzenes (e.g. of 9) are below 69 Kcal/mole.

Very recently obtained results with the acetone triplet ($E_T = 78 \text{ Kcal/mole}^{17b}$) indicate that this energy is sufficient for the cleavage of most methyl-S bonds in methyl aryl sulfides and sulfoxides.^{14b}

H ATOM SOURCES

The methyl radicals formed in the photocleavage processes of sulfoxides and of sulfides give polarized methane by an H atom abstraction step. As the present studies were mostly carried out in perdeuterated benzene the absence of H—D splitting in the methane signal indicates that the abstracted H atoms originate from the substrate molecules. In this solvent direct abstraction would be unlikely, but an addition-abstraction mechanism, e.g.,

$$CH_{3} + C_{6}H_{6} \longrightarrow CH_{3} \longrightarrow CH_{4} + CH_{3}C_{6}H_{5}$$

$$(12)$$

would be still energetically feasible. Abstraction from solvent has also not been observed in other solvents such as acetonitrile, acetone and chloroform. H—D splitting is however evident in methane formed in methanol-d₄ solution.

While no detailed data are available on the hydrogen abstraction step beyond the evidence that the H atom originates usually from the substrate molecules it seems that the abstraction follows an addition-abstraction path analogous to (12). This mechanism was indeed invoked in our previous studies of Norrish type I processes.¹⁹

EXPERIMENTAL

For the preparation of **5**, **6**, and **9** see Ref. 20, for that of **10**-Ref. 21, and for the preparation of **7** and **11** see Ref. 22. All ¹H photo-CIDNP measurements were carried out at 90 Mhz on a Bruker HFX-10 NMR spectrometer operating in the Fourier-transform mode. A 2500 W mercury-xenon lamp was used as a light source. Each radio frequency pulse was preceded by a 1-2 sec light period. For full experimental details, see previous publications. ^{4b,23} Typically 0.2 M solutions in benzene d₆ were used, tetramethylsilane (TMS) serving as chemical shift standard; each spectrum was obtained from 8 free-induction decay accumulations.

ACKNOWLEDGMENTS

We thank the Technische Universität Berlin, the Deutsche Forschungsgemeinschaft as well as the Gesellschaft von Freunden der Technischen Universität Berlin for their financial support.

Reinhard Lüdersdorf is greatly indebted to the Wigner-Stiftung, the Hermann Schlosser-Stiftung, the European Photochemistry Association, and the Gesellschaft von Freunden der Technischen Universität for postdoctoral research fellowships.

REFERENCES AND NOTES

- (a) Part IV in "CIDNP Studies of Photochemical Paths of Sulfur Compounds." For Part I see Ref.
 for Part II—Ref. 3 and for Part III—Ref. 4b.
- (b) Also: Part XLIV in "Organic Photochemistry" as well as Part LV in "Organosulfur Compounds" and Part XXIII in "Spectroscopic Investigations." For preceding paper in this series see Ref. 4.
- 2. M. Weinstein, K. A. Muszkat and J. Dobkin, J. C. S. Chem. Comm., 68 (1975).
- 3. K. A. Muszkat, K. Praefcke, I. Khait and R. Lüdersdorf, J. C. S. Chem. Comm., 898 (1979).
- (a) Part XLIII: M. Dankowski and K. Praefcke, *Phosphorus and Sulfur*, in print.
 (b) Part XXII and Part LIV, respectively: I. Khait, R. Lüdersdorf, K. A. Muszkat, and K. Praefcke, J. C. S. Perkin II. 1981, in print.
- 5. For reviews and leading references on photochemical processes of organosulfur compounds, see: (a) E. Block, *Quart. Rep. Sulfur Chem.*, (Int. J. Sulfur Chem.) 4, 237 (1969).
 - (b) E. Block, Reactions of Organosulfur Compounds, Academic Press, 1978.
 - (c) J. D. Coyle, Chem. Soc. Rev., 4, 531 (1975).

- (d) H. Dürr, in E. Müller, ed., "Methoden der Organischen Chemie, Photochemie, part II (Houben-Weyl)" IV/56, 1032, Thieme, Stuttgart, 1975.
- (e) A. I. Khodair, T. Nakabayashi and N. Kharash, Int. J. Sulfur Chem., 8, 37 (1973).
- (f) J. R. Shelton and K. E. Davis, Int. J. Sulfur Chem., 8, 217 (1973).
- (g) K. Gollnick and H. U. Stracke, Pure Appl. Chem., 33, 217 (1973).
- (h) K. Mislow, M. Axelrod, D. R. Rayner, H. Gotthardt, L. M. Coyne and G. S. Hammond, J. Amer. Chem. Soc., 87, 4958, 4959 (1965).
- (k) K. Mislow, Rec. Chem. Progress, 28, 217 (1967).
- (1) G. M. Gurria and G. H. Posner, J. Org. Chem., 38, 2419 (1973), and literature cited therein.
- 6. Chemically Induced Dynamic Nuclear Polarization. See, e.g., reviews by R. Kaptein, R. G. Lawler, H. D. Roth and G. L. Closs in Ref. 7 for descriptions of the Radical Pair model of CIDNP. The usual nomenclature of Ref. 7 will be followed. The sign Γ of the observed polarization in nucleus i of free radical A' in electron spin correlated radical pair A' + B' is given by the sign product rule

$$\Gamma = \mu \cdot \epsilon \cdot \Delta g \cdot A_i \tag{a}$$

 μ is the total electron spin state of A + B . μ + (triplet), μ - (singlet). ϵ is the path parameter. ϵ + (collapse), ϵ - (escape). Δg is the sign of the g-factor difference g(A') - g(B'), and A_i is the sign of the hyperfine nuclear spin-electron spin interaction of atom i in A'. Nuclear polarization is denoted by an asterisk (*).

- L. T. Muus et al. Chemically Induced Magnetic Polarization, NATO ASI Series, Vol. 34, D. Reidel, Dordrecht, 1977.
- 8. R. Lüdersdorf, I. Khait, K. A. Muszkat and K. Praefcke, in preparation.
- For discussions of neighboring group effects in sulfoxides see F. Montanari, Int. J. Sulfur Chem., C6, 137 (1971); D. Landini, F. Rolla and G. Torre, Int. J. Sulfur Chem., A2, 43 (1972); S. Allenmark, O. Bohman, C. E. Hagberg and H. Johnsson, Int. J. Sulfur Chem., 2, 191 (1972); S. Allenmark, Int. J. Sulfur Chem., 8, 127 (1973).
- G. Vermeersch, J. Marko, N. Fabvay-Garot, S. Caplain, A. Couture and A. Lablanche-Combier, Tetrahedron, 34, 2453 (1978).
- 11. The alternative structure for 5 (e.g., 4-methyl-2-methylsulfinyl-1-methylthiobenzene) can be ruled out with certainty since the observed coupling constant of 6-H (lowest field proton) is $J_{5,6} = 8$ hz indicating ortho coupling to a second proton. In the other case a meta coupling of only 2-3 hz would have been expected.
- 12. (a) R. G. Lawler, Ref. 7, p. 18.
 - (b) P. B. Ayscough, Electron Spin Resonance in Chemistry, Methuen, London 1966.
 - (c) R. W. Fessenden and R. H. Schuler, J. Chem. Phys., 39, 2147 (1963).
 - (d) B. C. Gilbert, C. M. Kirk, R. O. C. Norman and H. A. H. Laue, J. Chem. Soc., Perkin II, 497 (1977).
- 13. At 4°K compounds 5-7 and 9-11 in both polar (ethanol) and nonpolar (methylcyclohexane-methylcyclopentane) media are efficiently converted to the triplet state by direct excitation. In polar media these compounds have significant phosphorescence quantum yields. In polar media these compounds have significant phosphorescence quantum yields.
- 14. (a) I. Sofer and K. A. Muszkat, in preparation.
 - (b) R. Lüdersdorf, I. Khait, I. Sofer and K. A. Muszkat, in preparation.
- 15. (a) S. W. Benson, Chem. Rev., 78, 23 (1978).
 - (b) J. A. Kerr, Chem. Rev., 66, 465 (1966).
- 16. J. Guttenplan and S. G. Cohen, J. C. S. Chem. Comm., 247 (1969).
- 17. N. J. Turro, Modern Molecular Photochemistry, Benjamin, Menlo Park, 1978.
 - (a) N. J. Turro, Modern Molecular Photochemistry, Ch. 2,
 - (b) N. J. Turro, Modern Molecular Photochemistry, Ch. 9.
- 18. R. S. Cooke and G. S. Hammond, J. Amer. Chem. Soc., 90, 2958 (1968); 92, 2739 (1970).
- 19. C. Bak, K. Praefcke, K. A. Muszkat and M. Weinstein, Z. Naturforsch., 32b, 674 (1977).
- 20. P. Margaretha, Helv. Chim. Acta, 62, 1978 (1979).
- 21. T. Zincke and W. Kruger, Ber., 45, 3474 (1912).
- 22. T. Zincke and W. Frohneberg, Ber., 42, 2721 (1909).
- (a) K. A. Muszkat and M. Weinstein, J. Chem. Soc., Perkin II, 1976, 1072; Z. Phys. Chem. N.F., 101, 105 (1976).
 - (b) K. A. Muszkat and C. Gilon, *Biochem. Biophys. Res. Comm.*, 79, 1059 (1977); *Nature*, 271, 685 (1978).
 - (c) K. A. Muszkat and I. Khait, Bull. Soc. Chim. Belg., 88, 933 (1979).